



L Number	Hits	Search Text	DB	Time stamp
2	244	((insulating or dielectric) same (etch\$3	USPAT;	2003/04/18
2	277	or remov\$3) same (C4F8 or	EPO; JPO;	07:17
		"C.sub.4F.sub.8" or C5F8 or	IBM TDB	0,11,
		"C.sub.5F.sub.8" or fluorocarbons)) and	I DIT_ I DIS	
		("etch stop" or SiN or "silicon nitride")		
				1
	2	and (trench or via or "contact hole") (etch\$3 or remov\$3) same ((C4F8 or	USPAT;	2003/04/18
4	2		EPO; JPO;	09:41
	!	"C.sub.4F.sub.8") same (C5F8 or		09.41
		"C.sub.5F.sub.8"))	IBM TDB	2002/04/19
6	3	(C4F8 or "C.sub.4F.sub.8" or	USPAT;	2003/04/18
		octafluorocyclobutane) with (C5F8 or	EPO; JPO;	08:23
		"C.sub.5F.sub.8" or	IBM_TDB	
	!	octafluorocyclopentence)		2222/24/22
1	592	(insulating or dielectric) same (etch\$3	USPAT;	2003/04/18
		or remov\$3) same (C4F8 or	EPO; JPO;	10:45
		"C.sub.4F.sub.8" or C5F8 or	IBM_TDB	j
		"C.sub.5F.sub.8" or fluorocarbons)		
12	17	(etch\$3 or remov\$3) same (C5F8 or	USPAT;	2003/04/18
		"C.sub.5F.sub.8")	EPO; JPO;	09:51
			IBM_TDB	1
15	19	(etch\$3 or remov\$3) and (C5F8 or	USPÃT;	2003/04/18
		"C.sub.5F.sub.8")	EPO; JPO;	09:56
			IBM TDB	
16	1	5338399.pn.	USPAT;	2003/04/18
	_		EPO; JPO;	10:20
			IBM TDB	}
17	20	((insulating or dielectric) same (etch\$3	USPAT;	2003/04/18
	20	or remov\$3) same (C4F8 or	EPO; JPO;	10:20
		"C.sub.4F.sub.8" or C5F8 or	IBM TDB	1
		"C.sub.5F.sub.8" or fluorocarbons)) and	1011_101	1
		"partial pressure"	ļ	1
18	87	(insulating or dielectric) same (etch\$3	USPAT;	2003/04/18
18	0 /		EPO; JPO;	11:07
		or remov\$3) same (C4F8 or	IBM TDB	11.07
		"C.sub.4F.sub.8" or C5F8 or	I TOM_I DO	}
		"C.sub.5F.sub.8" or fluorocarbons) same	j	}
		(plug or copper or Cu or wiring)	*************	2002/04/18
19	3066	(insulating or dielectric) and (etch\$3	USPAT;	2003/04/18
		or remov\$3) and (C4F8 or "C.sub.4F.sub.8"	EPO; JPO;	11:09
		or C5F8 or "C.sub.5F.sub.8" or	IBM_TDB	1
		fluorocarbons) and (plug or copper or Cu	}	
		or wiring)		0000/04/70
20	726		USPAT;	2003/04/18
		or remov\$3) and (C4F8 or "C.sub.4F.sub.8"	EPO; JPO;	11:09
		or C5F8 or "C.sub.5F.sub.8" or	IBM_TDB	
		fluorocarbons) and (plug or copper or Cu]	
		or wiring)) and (selective or		
		selevtivity)	1	
21	226	" = ' ' 4'	USPAT;	2003/04/18
		or remov\$3) and (C4F8 or "C.sub.4F.sub.8"	EPO; JPO;	11:10
		or C5F8 or "C.sub.5F.sub.8" or	IBM TDB	
		fluorocarbons) and (plug or copper or Cu	_	
		or wiring)) and (selective or	(
		selevtivity)) and 438/\$.ccls.	}	
22	2108	((438/706) or (438/710) or (438/712) or	USPAT;	2003/04/18
22	2100	(438/700) Of (438/710) Of (438/712) Of (438/720)).CCLS.	EPO; JPO;	11:10
		(430/720//.0043.	IBM TDB	11.10
22	0.5	///420/706\ om /420/710\ om /420/712\ om	USPAT;	2003/04/18
23	96			
		(438/720)).CCLS.) and ((insulating or	EPO; JPO;	11:10
		dielectric) and (etch\$3 or remov\$3) and	IBM_TDB	
		(C4F8 or "C.sub.4F.sub.8" or C5F8 or		
		"C.sub.5F.sub.8" or fluorocarbons) and		
Į.		(plug or copper or Cu or wiring))	ļ	